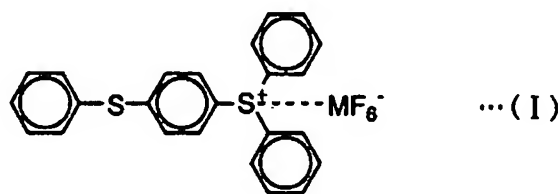


**Amendments to and listing of the Claims:**

Please amend claims 3-8 as follows. This listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Original) A resin composition for stereolithography, which is an actinic radiation-curable resin composition comprising:
  - a cationic-polymerizable organic compound;
  - a radical-polymerizable organic compound;
  - a photo initiator for cationic polymerization; and
  - a photo initiator for radical polymerization,
 wherein the photo initiator for cationic polymerization comprises a compound represented by the following formula (I), the compound having a purity of 80% or higher:



wherein M represents an antimony atom or a phosphorus atom; and the broken line between  $\text{S}^+$  and  $\text{MF}_6^-$  represents an ionic bond.

2. (Original) The resin composition for stereolithography as claimed in claim 1, wherein the purity of the compound represented by the formula (I) is 90% or higher.
3. (Currently Amended) The resin composition for stereolithography as claimed in claim 1 ~~[[or 2]]~~, wherein the purity of the compound represented by the formula (I) is 95% or higher.
4. (Currently Amended) The resin composition for stereolithography as claimed in ~~any of claims 1 to 3~~ claim 1, wherein M in the compound represented by the formula (I) is an antimony atom.

5. (Currently Amended) The resin composition for stereolithography as claimed in ~~any of claims 1 to 4~~ claim 1, wherein the cationic-polymerizable organic compound comprises at least one compound having an epoxy group.

6. (Currently Amended) The resin composition for stereolithography as claimed in ~~any of claims 1 to 5~~ claim 1, wherein the radical-polymerizable organic compound comprises at least one compound having a (meth)acryl group.

7. (Currently Amended) The resin composition for stereolithography as claimed in ~~any of claims 1 to 6~~ claim 1, which comprises an oxetane compound at a ratio of from 1 to 30% by mass with respect to the mass of the cationic-polymerizable organic compound.

8. (Currently Amended) The resin composition for stereolithography as claimed in ~~any of claims 1 to 7~~ claim 1, which comprises a polyalkylene ether compound at a ratio of from 1 to 30% by mass with respect to the mass of the cationic-polymerizable organic compound.